# Low-Power Small-Area Digital I/O Cell

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Abstract—A novel low-power and small-area digital I/O cell is proposed in this work. The new input/output (I/O) cell drastically reduces the I/O power consumption, which has been considered as the major power dissipation of the whole chip. The maximum operating clock is 500 MHz given a 10-pF offchip load. On top of the power saving feature, the proposed cell occupies merely  $10535.2 = 4167.45 \, (transmitter) + 6367.8 \, (receiver) \, \mu m^2$  which is far less than any prior commercially available I/O and low-voltage differential signaling I/O cells. Physical measurements of the proposed I/O cells show that the delays of the transmitter and the receiver are 1.1 and 1.8 ns, respectively. The largest power/bandwidth of the proposed design is 38.9  $\mu$ W/MHz when transmitting.

Index Terms—Bidirectional, half swing, input/output (I/O) cell, medium threshold, zero threshold.

### I. Introduction

N OBSTRUCTION in the digital transmission of chips via longs wires on the printed circuit bodard (PCB) is the input/output (I/O) cells which are responsible for voltage level shifting and electrostatic discharge (ESD) protection [5]. Besides, long wires mean huge R and C loads to the I/O cells. The I/O cells, namely I/O pads, are asked to supply sufficient current to drive these large loads. Hence, not only is the pad area large, but also the power consumption occupied a great portion of the overall power. Most of prior CMOS I/O cells utilized very large area to accommodate large driving transistors as well as large passive elements [2], [7]. The price to pay is more power dissipation. Thus, the voltage scaling is one of the most effective strategies to reduce power [1]. As the supply voltage of the chip is dropped, the switching speed of the I/O pads is reduced proportionally which in turn neutralize the high-speed performance of any CMOS digital core design. In this paper, we tend to propose a novel I/O cell design to resolve the dilemma. The output voltage swing in the transmitter of our new cell is reduced to about half of the supply voltage. In the mean time, the high-speed and high-throughput digital core design is not affected by using a feedback loop containing transistors with different threshold voltages. The power dissipation is also drastically reduced. The receiver of the proposed I/O cell, on the other way around, restores the signal level such that it can be faithfully

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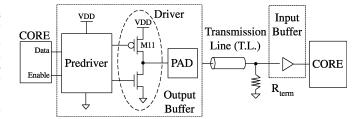


Fig. 1. Traditional I/O cells ( $R_{\text{term}}$  is a terminator.).

decoded to be the original data. Neither reference bias nor passive element is required in the proposed design. The overall cell size implemented by CMOS 0.25- $\mu$ m 1P5M process is  $10\,535.24=4167.45$  (transmitter)+6367.79 (receiver)  $\mu$ m², while the power dissipation is 12.04=7.78 (transmitter)+4.26 (receiver) mW at 200 MHz. The worst-case delay is measured to be 1.1 and 1.8 ns, respectively, for the transmitter and receiver.

#### II. LOW-POWER I/O CELL DESIGN

A typical I/O cell design in digital data transmission is shown in Fig. 1. The predriver, when enabled, supplies the gate drive to the driver composed of a pair of huge pMOS and nMOS transistors to steer a large current to or from the long wire. This traditional design can not directly be voltage scaled so as to achieve the power saving by  $P = f \cdot C \cdot V^2$ , where f is the switching frequency, C is the load, and V is the supplied voltage. The reason is obvious: if the supplied voltage of the driver is shifted from VDD (supply voltage) to 1/2 VDD, the drain current of M11 becomes

$$I_D = \frac{\beta}{2} (V_{SG} + V_{thp})^2 \left[ 1 + \lambda (V_{SF} - V_{SD,sat}) \right]$$
 (1)

where  $V_{\rm SG}$  is the voltage drop between the source and the gate of M11,  $V_{\rm SF}$  is that between the source and the drain of M11. The decrease of  $V_{\rm SF}$  caused by the shrinkage of the supplied voltage results in the decrease of  $I_D$ . Thus, the driving capability as well as the speed is deteriorated.

Adding a reference 1/2 VDD bias to the driver pair might be considered as a good idea. Regardless of using a bandgap bias or a second voltage supply, the area penalty is highly unacceptable since the load is large. On top of this drawback, the reference 1/2 VDD bias usually has a poor driving capability which severely affects the supplied voltage of the driver pair. The consequence could be malfunction and large power dissipation.

## A. Transmitter of the Proposed I/O Cell

Thanks to advanced processes provided by the Taiwan Semiconductor Manufacturing Company (TSMC), transistors with various threshold voltages are feasible in 0.25- $\mu$ m or

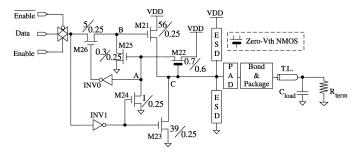


Fig. 2. Trasmitter of the proposed I/O cell ( $R_{term}$  is a terminator.).

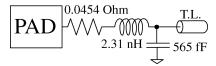


Fig. 3. Wiring model between the pads.

better CMOS technology. The proposed I/O cell consists of a transmitter (TX) and a receiver (RX) which will be introduced in the following text.

Referring to Fig. 2, which is the proposed transmitter, Data and Enable are signals generated by the digital core. ESD is the electrostatic discharging circuitry for the purpose of protection [3]–[5]. The model of the pad as well as the bonding wire and package is shown in Fig. 3 [6]. The operation of the transmitter is described as follows.

- T1) When Data is low and Enable is high, inverter INV1 turns on M23 and M24 which in turn pull down node C and A, respectively, to ground. Then, the low voltage at node A turns on M26 via INV0.
- T2) As soon as Data turns high, a wide M26 turns on M21 right away. Node C, thus, will be charged to around 0.1 V very shortly which turns on the zero- $V_{\rm th}$  nMOS, M22. The voltage at node A then is boosted to VDD. Thus, M26 is off and M25 is turned on to ground node B which in turn shuts down M21. The charging operation to node C is then terminated. The final voltage level of node C after the mentioned procedure will be kept around  $1/2 \times {\rm VDD}$ .

Since neither reference bias nor passive element is used in the design, the transmitter size is extremely small. Notably, in order to avoid the racing problem which might occur in the procedure of shutting down M21. We have to ensure that M26 is turned off before M25 is on. Otherwise, a large dc current will be induced. The design of inverter INV0 is different from the rest of the inverters. The pulldown transistor in INV0 is a zero- $V_{\rm th}$  nMOS, as shown in Fig. 4. The threshold voltage of the zero- $V_{\rm th}$  nMOS, which provides a high sensitivity to the variation of the voltage at node A, is 0.2 V [8]. Hence, the gate drive at M26 will be discharged very quickly. The final voltage level at node C does not have to be very precisely a  $1/2 \times VDD$ , which is the "high" of the output of the transmitter. It will drift due to the temperature, process variation, or loading. As long as the a logic "1" sent by the proposed transmitter is above 0.8 V for all process corners, it can be recovered correctly by the sophisticated receiver design which will be illustrated in the following section.

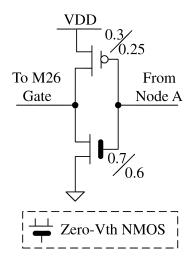


Fig. 4. Schematic of INVO.

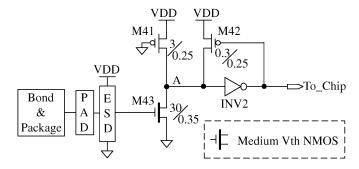


Fig. 5. Receiver of the proposed I/O cell.

## B. Receiver of the Proposed I/O Cell

The signal delivered by the transmitter will be contaminated seriously by the noise and crosstalk of the transmission lines. The quality of the signal present at the receiver is expected to be poor. Referring to Fig. 5, the received signal appears at the gate of M43 via pad and ESD circuitry. The threshold voltage of M43 is chosen to be a medium  $V_{\rm th}\approx 0.4$  V. (Note: The medium- $V_{\rm th}$  transistors are available in TSMC 0.25- $\mu$ m 1P5M process and better processes.) The function of the receiver is described as follows.

- R1) When the gate drive of M43 is low to turn off M43, node A is charged to VDD. Hence, the To\_Chip signal is low. The weak feedback latch composed of INV2 and M42 stabilizes the signal to the digital core.
- R2) If the gate drive of M43 turns high, M43 will be turned on to discharge node A. To\_Chip signal, thus, is pulled high.

As long as the voltage of the gate drive of M43, which is the received signal via the pad and ESD, is higher than the pre-determined 0.4 V, the voltage level of the signal sent to the internal digital core can be restored to VDD.

## III. PHYSICAL MEASUREMENTS

Both the proposed transmitter and receiver pass all supply voltage (2.25 V  $\sim$  2.75 V), model (FF, TT, and SS), and temperature ( $-25^{\circ}\text{C} \sim 75^{\circ}\text{C}$ ) corner simulations. Figs. 6 and 7 show the partial simulations. The test key die photo of the proposed

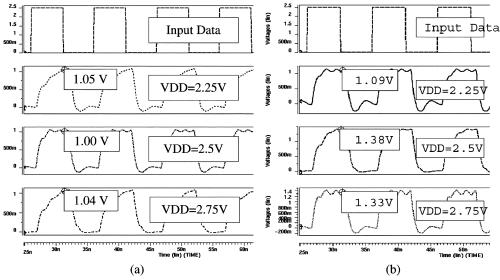


Fig. 6. Transmitter simulation at VDD =  $2.25 \text{ V} \sim 2.75 \text{ V}$ . (a) FF model ( $-25 ^{\circ}\text{C}$ ). (b) SS model ( $75 ^{\circ}\text{C}$ ).

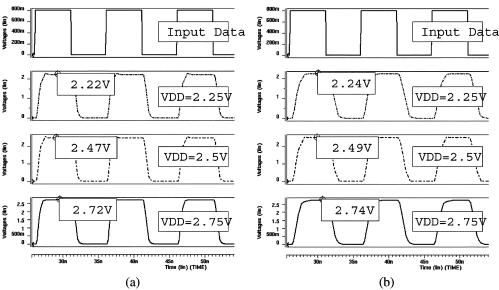


Fig. 7. Receiver simulation at VDD =  $2.25 \text{ V} \sim 2.75 \text{ V}$ . (a) FF model ( $-25 ^{\circ}\text{C}$ ). (b) SS model ( $75 ^{\circ}\text{C}$ ).

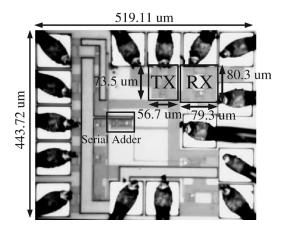


Fig. 8. Die photo of the proposed I/O cell.

I/O design is shown in Fig. 8. Tektronix TDS 680B oscilloscope, HP 33120A Function Generator, Agilent 33250A, HP 54616C, and HP 1660CP Logic Analyzer are used to measure the performance of the proposed I/O cell. Figs. 9 and 10, respectively,

TABLE I PHYSICAL MEASUREMENTS OF PROPOSED DESIGN

	transmitter	receiver		
	(output load = 18 pF)	(input load = 9 pF)		
input swing	2.5 V	0.8 V		
power	7.78 mW @ 200 MHz	4.26 mW @ 200 MHz		
area	$73.5 \times 56.7 \ \mu \text{m}^2$	$80.3 \times 79.3 \ \mu \text{m}^2$		
propagation delay	1.1 ns	1.8 ns		
max. current	3.11 mA	1.70 mA		
$V_{IH}$	> 1.3 V	> 0.52 V		
$V_{IL}$	< 1.0 V	< 0.48 V		
$V_{OH}$	[0.75, 1.25] V	[2.33, 2.9] V		
$V_{OL}$	[-0.3, 0.2] V	[-0.5, 0.25] V		
rise time	1.32 ns	4.0 ns		
fall time	1.8 ns	3.0 ns		
max. frequency	500 MHz	250 MHz		

demonstrate the measurement waveforms of the outputs of the transmitter and the receiver.

Fig. 11 is the output of a built-in testing serial adder of which the input is increasing from 000 to 111 monotonically. The serial adder is used for testing the cooperation between the proposed

	Power (μW/MHz)		Area (mm²)		Delay (ns)		Process
	transmitter	receiver	transmitter	receiver	transmitter	receiver	
TSMC I/O	215.88		0.01	.88	1.84	1.4	$0.25~\mu m$ CMOS
	(PCI66DGZ)		(PCI66DGZ)				
LVDS I/O [2]	43	33	0.175	0.081	0.8	1.4	$0.35 \mu m CMOS$
Ours	38.9	21.3	0.00416745	0.0063678	1.1	1.8	$0.25~\mu\mathrm{m}~\mathrm{CMOS}$

TABLE II
COMPARISON TO PRIOR DESIGNS (NOTE: PCI66DGZ IS A BIDIRECTIONAL I/O CELL)

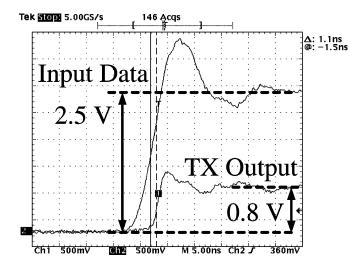


Fig. 9. Measured output of the transmitter.

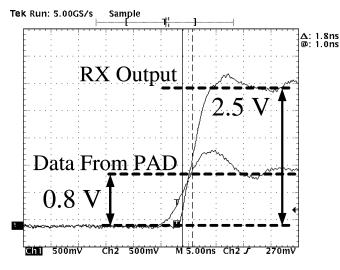


Fig. 10. Measured output of the receiver.

transmitter and the proposed receiver. The serial adder accumulates the input from the proposed receiver and outputs a carry by the transmitter. All of the functions are verified to be correct. The overall characteristics of the I/O cell is summarized in Table I.

In the same testing condition (namely, 25 °C, transmitter load = 18 pF, and receiver load = 9 pF), we have compared the performance of our proposed I/O cell with two prior designs in Table II. Except that the delay is a little

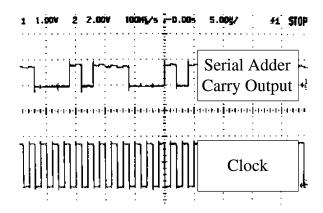


Fig. 11. Measured output of the built-in serial adder.

worse than that of LVDS I/O cells, our design outperforms in the power and area categories.

#### IV. CONCLUSION

We propose a novel I/O cell design taking advantage of transistors with different threshold voltages to achieve low power and small area. Besides, the sacrifice in terms of delay is obscure. Thorough post-layout simulations and the physical measurements confirm the superiority of our design regarding power dissipation and area.

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